Pt Deposition on Anode Enhances the Performance of Dye-Sensitized Solar Cell with Non-Cross-Linked Gel Electrolyte

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ABSTRACT

We fabricated dye-sensitized solar cells with non-cross-linked fluorinated gel electrolyte. The application of fluorinated gel to electrolyte is a challenging issue at present. The gelation of the electrolyte is of importance in order to solve the problem in the durability of the cell. We investigated, in this article, the effect of Pt deposition on the anode of the cell. The Pt was deposited by means of a DC sputtering technique. The studies showed that the deposition time strongly affected both open voltage and short-circuit current of the cell. The adaptive thickness of the Pt layer was determined to be 10 nm for the non-cross-linked fluorinated gel electrolyte cells.

Keywords: Ruthenium Ion Complex; Dye-Sensitized Solar Cell; Non-Cross-Linked Fluorinated Gel Electrolyte; Pt Layer; DC Sputtering Deposition

1. Introduction

Dye-sensitized solar cells have attracted much attention these twenty years, since this new type of solar cells without any pn junctions was reported [1,2] in 1991 for the first time. The vast amount of efforts has been devoted to the improvement of its performance [3,4]. The conversion efficiency has reached ten percents [5] and so the application is now expected strongly. In order to replace this kind of solar cells with the silicon ones, the efficiency requires the same level of silicon solar cells at least. Recently large size of cells was fabricated with maintaining conversion efficiency [6].

The other big problem of the dye-sensitized solar cells is its poor durability. Since the cell includes electrolyte as one side of the electrodes, the leakage of the electrolyte inevitably limits its durability. As a preferable idea to prevent the electrolyte leakage, gelation of the electrolyte has been proposed [7,8]. Some researchers have been challenging with cross-linking of a polymer [9]. We have been engaged on the other hand in the application of non-cross-linked fluorinated gel electrolytes that have already been proposed to apply to a secondary battery [10]. The non-cross-linked fluorinated gel electrolyte does not require any bridging process of chemical reaction such as ultraviolet irradiation, having an advantage of a simple and low-cost gelation procedure from the viewpoint of manufacturing.

The cell consists of two transparent electrodes, between which the gel electrolyte is put, where one of the electrode was covered with the aggregate of TiO₂ nanoparticles adsorbing dye. The aggregated nanoparticle TiO₂ layer—often addressed nanoporous TiO₂—is one of the critical part of the solar cell [5,11]. Nowadays, TiO₂ coated stainless grid has been challenged for the purpose of low cost [12-14]. On the other hand, the counter electrode has not been well studied yet. The most simply way to form the cell, only FTO substrate is used as a counter electrode. Some researchers have studied coating effect of the FTO counter electrode. For example, Pt films sputtered on FTO improved the cell performance till the sputtering time was 90 s at most [15]. It has been reported that a kind of polymer over Pt enhanced the performance to 2.84% [16]. There is another report that carbon was better than Pt and that surface roughness affected open voltage noticeably [17]. Very recently, gra-
phite and pencil-lead was applied on FTO counter electrodes [18]. The interesting results have been reported that carbon and platinized Sb-doped SnO₂ powder was sprayed on ITO [19].

We fabricated the cells with a variation of sputtering time of Pt deposited on FTO counter electrodes; ranging between 1 and 6 min, which corresponds to 5 and 30 nm, respectively. We then studied the influence on the performance of the cells from the point of view of I-V characteristics.

2. Experimental Details

We mixed 1 g of slurry (P4TH055 offered by Sumitomo Titanium) including 30 wt% of TiO₂ with polyethylene glycol (PEG), the amount of which was 10 wt% of the slurry, to make paste with the help of the addition of Triton X (a nonionic surfactant of 15 μl) to increase viscosity. The size of TiO₂ particles in the slurry is not claimed clearly, but ranging between 50 - 70 nm. Further P-25 of titania nano particles (20 nm) were added to enhance the cell performance. The amount of added P-25 was the same weight as the TiO₂ in the slurry. The paste was spread on a fluorine doped tin oxide (FTO) substrate at the thickness of 58 μm. Further P-25 of titania nano particles (20 nm) were added to enhance the cell performance. The amount of added P-25 was the same weight as the TiO₂ in the slurry. The paste was spread on a fluorine doped tin oxide (FTO) substrate at the thickness of 58 μm. This was then annealed at 450°C for 30 minutes to remove binders and solvent to be a cathode. The TiO₂ deposited substrate was soaked in a solution of ruthenium complex dye (Ru(4,4’-dicarboxy-2,2’bipyridine)₂(NCS)₂) in ethanol (1 × 10⁻⁴ mol/l) at 50°C for 2 hours to adsorb the dye.

The counter electrode (anode) of an FTO substrate was sputtered with a Pt target using a portable sputtering apparatus of VPS-020 by ULVAC. The sputtering time was varied between 1 and 6 minutes. The thickness of Pt was confirmed by means of an interference microscope.

We describe here the preparation of gel electrolyte. Dimethyl sulfoxide was mixed with LiI (10 mmol/g) for 20 minutes with the help of ultrasonic agitation. We then added 2-acrylamid-2-methyl-propanesulfonic acid (AMPS) to this solution and mixed for 200 minutes further. The AMPS is one of fluorinated oligomers [10]. The amount of AMPS added for gelation should be roughly larger than 330 g/l; the critical gelation density that was obtained experimentally. If the density of the AMPS is too low, spontaneous cohesion is possibly hard to occur owing to a large distance between each oligomer. We finally formed a solar cell by putting the gel electrolyte between a cathode and anode and sealed the environs of the cell with epoxy resin.

We investigated the I-V characteristics of the solar cells by measuring the current and voltage appeared at the cell when a variable resistive load was connected to the cell that was irradiated by white light (AM 1.5) from a Xenon lamp (UXL500SX by Ushio) at the intensity of 55 mW/cm². The resistive load was varied between 0 and 100 kΩ.

3. Results and Discussion

We show the I-V characteristics in Figure 1 obtained from the solar cell exposed in the white light. The thickness of Pt determined with an interference microscope was 5, 7, 9, 18 and 30 nm, which corresponds to the sputtering time of 1 to 6 minutes. The results show that the sputtering time of 3 minutes provided the maximum open voltage of 0.52 V and the maximum short-circuit current of 2.33 mA at the same time. The maximum generating power is shown in Figure 2 as a function of sputtering time. It is apparent that when the sputtering time was 3 minutes. The maximum generating power was noticeably as large as 0.56 mW. The FF value of this cell was 0.46 that is less than 0.48 of the cell with the sputtering time of 1 minute.

![Figure 1. The I-V characteristics of the cell exposed in the white light. The parameter of the sputtering time was varied between 1 and 5 minutes.](image1)

![Figure 2. The maximum output power of the cell as a function of the sputtering time. The power is maximum at the sputtering time of 3 minutes.](image2)
The experimental results described above are quite simple but have deep meanings. The Pt deposition enhances the cell performance but excess deposition suppresses it contrarily. It implies that slight Pt deposition is favorable but does not indicate that Pt electrode is not appropriate. With the longer sputtering time, it possibly provides the smooth Pt thin layer. We speculate that the speckled state of Pt seems to be critical for the high performance of the cell. The Pt state deposited on the FTO substrate is the next interesting point.

We consider the open voltage here. The photo voltage has been studied in relation to carrier injection at the cathode mainly [20-22]. The open voltage is dependent on temperature in the manner of 2.5 mV decrease with a degree increase in temperature. The fact suggests the shift of the TiO2 conduction band edge potential [21]. On the other hand, the variation of the open voltage is quite large in Figure 1. The open voltage of the cell with the sputtering time of 3 minutes was 0.52 V, which is twice as large as that of the cell with the 6 minutes sputtered cathode. This indicates the interface state between the cathode and the electrolyte is of importance to obtain a high open voltage. Based on the tendency to have a maximum at 3 minutes, it does not simply mean that the electrolyte-Pt contact is required. The large open voltage derived from the rough surface with unevenness of the anode. When the sputtering time becomes larger than 4 minutes, the Pt deposited surface becomes smooth again and then the open voltage decreased in accordance with it.

A large dependence was also observed in the short-circuit current in Figure 1. The biggest short-circuit current was 2.33 mA, which was also observed in the case of the sputtering time of 3 minutes. The value is 9.3 times as large as that in the 6 minutes sputtered sample. The short-circuit current is strongly dependent on the sputtering time of Pt deposition on the anode. T. Asano et al. have reported the short-circuit current depended on the sort of electrolyte noticeably [23]. They concluded that the larger diffusivity coefficient of the Iodine ions enhances the short-circuit current of the cell. Our experimental results shows, on the other hand, that the interface state between the electrolyte and anode strongly affects the short-circuit current. This means that the characterization of the anode is no less important than the cathode that includes TiO2 and light absorbing dyes. The speckled form of the Pt surface possibly enhances the electric field at the surface to make the electron injection in the electrolyte easy. The roughened surface may be favorable for the anode.

4. Conclusion
A dye sensitized solar cell with non-cross-linked fluorinated gel electrolyte was fabricated and then the effect of the Pt deposition on the anode was investigated. Pt layers were deposited by means of a DC sputtering method. The experimental results show that there is the optimized sputtering time, which corresponds to the Pt layer thickness of 9 nm. At the optimized condition, the open voltage, short-circuit current and generating power became the largest at the same time. The fact tells us that the anode circumstance is no less important than the TiO2 and dye state where the electric power is generated. We infer that surface roughness of the Pt layer is critical for the high performance of the solar cell.

REFERENCES
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